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SUBSTITUTE DRAWING		ISSUE CLASSIFICATION		PATENT NUMBER	
JPG3					
JPGM					
<b>U.S. UTILITY Patent Application</b>					
M1		O.I.P.E.		PATENT DATE	
SCANNED 10/03/01		QA		LA	
APPLICATION NO. 09/725853		CONT/PRIOR F	CLASS 438 257	SUBCLASS 462 797	ART UNIT 2812 2926
APPLICANTS	Masahiko Takeuchi Koichiro Narimatsu Atsushi Ueno				
TITLE	Photomask including auxiliary mark area, semiconductor device and manufacturing method thereof				
PTO-2040 12/99					

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____				ISSUE FEE	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	(Primary Examiner) _____ (Date) _____ (Legal Instruments Examiner) _____ (Date) _____			Amount Due	Date Paid
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